

2. (Amended) A method for manufacturing a reflection type liquid crystal display, comprising

forming plural scanning lines and plural signal lines crossing said scanning lines on an insulating substrate;

forming a switching element in each of picture element regions divided by said scanning lines and said signal lines;

forming an interlayer insulating film having appropriate unevenness of an inseparable pattern in the picture element region and having a contact hole of a separable pattern on a drain electrode of said switching element by plainly applying a photosensitive insulating resin on said substrate so as to dissolve difference in level caused by said scanning lines, said signal lines, and said switching element, and conducting exposure and development while changing an amount of exposure; and

forming a reflex picture element electrode having unevenness due to said interlayer insulating film at a position conforming to each of the picture element regions and which is electrically connected to said switching element through said contact hole, by patterning after forming a high reflex film on said interlayer insulating film, wherein

in the process of forming the interlayer insulating film, the insulating resin is exposed by divisional (split) exposure in which the inseparable pattern and the separable pattern are arranged on different masks, and

said inseparable pattern is exposed by a predetermined exposure amount of 20 to 80 % of the exposure amount for said separable pattern.

3. (Amended) A method for manufacturing a reflection type liquid crystal display, comprising

forming plural scanning lines and plural signal lines crossing said scanning lines on an insulating substrate;

forming a switching element in each of picture element regions divided by said scanning lines and said signal lines;

forming an interlayer insulating film having appropriate unevenness of an inseparable pattern in the picture element region and having a contact hole of a separable pattern on a drain electrode of said switching element by plainly applying a photosensitive insulating resin on said substrate so as to dissolve difference in level caused by said scanning lines, said signal lines, and said switching element, and conducting exposure and development while changing an amount of exposure; and

forming a reflex picture element electrode having unevenness due to said interlayer insulating film at a position conforming to each of the picture element regions and which is electrically connected to said switching element through said contact hole, by patterning after forming a high reflex film on said interlayer insulating film, wherein

in the process of forming the interlayer insulating film, a mask is used in exposing the insulating resin and has a shading material comprised of at least two layers, the at least two layers including an ultraviolet filter layer for cutting ultraviolet rays at a predetermined value of 20 to 80 % in a base material, and said ultraviolet filter layer is laid in a mask pattern opening portion located conforming to the picture element region.

4. (Twice Amended) A reflection type liquid crystal display manufactured according to claim 2.

5. (Amended) A mask for manufacturing a reflection type liquid crystal display, the liquid crystal display including a first insulating substrate provided with scanning lines and signal lines formed into a lattice configuration, a TFT, an interlayer insulating film, and a reflex picture element electrode; a second insulating substrate having a color filter and an opposed electrode and arranged opposite to the first insulating substrate; and a liquid crystal between said substrate; the mask comprising:

a shading material of at least two layers, the at least two layers including an ultraviolet filter layer for cutting ultraviolet rays at a predetermined value of 20 to 80 % in a base material, said ultraviolet filter layer being laid in a mask pattern opening portion located conforming to a picture element region.

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Please add the following:

AZ
--18. (New) A reflection type liquid crystal display manufactured according to claim 3.--

IN THE ABSTRACT:

Please delete the entire abstract and replace with the following:

AB
--A reflection type liquid crystal display is formed by an interlayer insulating film having appropriate unevenness of an inseparable pattern in a picture element region and having a contact